



Obducat receives order for an EITRE[®] 3 NIL-system from a leading institute in India

OBUDUCAT AB (publ) subsidiary Obducat Technologies AB, a leading supplier of lithography solutions based on nanoimprint lithography (NIL), has received an order from a leading institute in India, for the supply of an EITRE 3 NIL-system. The order value amounts to approx. 1.1 million SEK.

The EITRE 3 system will be installed in the cleanroom facilities of the institute where it will be used for R&D work within a wide area of interdisciplinary research activities in the broad domain of applied physics. The Eitre 3 system will be used to perform nanolithography processes for various purposes.

The EITRE 3 system is planned to be delivered in the fourth quarter this year.

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About Obducat AB (publ)

Obducat AB (publ) is an innovative developer and supplier of technologies, products and processes used for the production and replication of advanced micro and nano structures. Obducat's products and services serve the demands of companies within the LED, OLED, semiconductor, displays, biomedical and MEMS industries. Obducat's technologies include nano imprint technology, coating technology and wet processing technology. Obducat has offices in Sweden, Germany and China and the headquarter is located in Lund, Sweden. Obducat is a public company. Obducat's shares are traded on the Swedish NGM Main Regulated Equity exchange. Read more at www.obducat.com.